

PATENT APPLICATION

PATENT AND TRADEMARK OFFICE IN THE UNITED ST

In re application of

Nobuo SHIMAZU, et al.

Appln. No.: 09/732,927

Group Art Unit: Unknown

Filed: December 11, 2000

Examiner: Unknown

For:

MANUFACTURING METHOD OF MASK FOR ELECTRON BEAM

PROXIMITY EXPOSURE AND MASK

DECLARATION ACCOMPANYING ENGLISH TRANSLATION

Honorable Commissioner of Patents Washington, D.C. 20231

Sir:

I, Kenzo MATSUURA, residing at 1-12-19 Mukohara, Aso-ku, Kawasaki-shi, Kanagawa, Japan hereby declare that:

I am familiar with both the Japanese and English language.

I have prepared the English translation attached hereto of the above-identified Japanese-language application.

I believe that the attached English translation is a true, faithful and exact translation of the corresponding Japanese-language application.

I further declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application or any patent issuing thereon.

Date: May 25, 2001

Translator, Japanese patent attorney